NPIC ROUTING SLIP Approved For Release 2005/02/17 : CIA-RDP78B04770A001400030007-8

FROM:	IAD/OSS			DATE: 23 Feb. 166	
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Approved For Release 2005/02/17 : CIA-RDP78B04770A001400030007-8

25X1

Approved For Release 2005/02/17 CIA-RDP78B04770A001400030007-8

IAD/OSS - 66/66 24 February 1966

	MEMORANDUM FOR:	Assistant for Plans & Development, NPIC				
25X1	ATTENTION :[
	FROM :	Chief, Imagery Analysis Division, CIA				
	SUBJECT :	Rapid Access Contact Printer				
-	REFERENCES :	 (a) IAD Memorandum, OSS-13/66, dated 13 January 1966, Subject: Request for Development ActionRapid Access Contact Printer (b) Memorandum NPIC/P&DS/D/6-739, dated 24 Jan. 1966, Subject: Rapid Access Contact Printer (c) Draft copySpecification for Rapid Access Contact Printer 				
25X1	1. On 16 February P&DS, discussed the above					
25X1	referenced draft of specifications for a Rapid Access Contact Printer with					
25X1	resolution of 400 lines per millimeter; this change was discussed with and it was agreed that 350 lines per millimeter would be satisfactory for IAD's needs at this time.					
=	2. As a point to be considered as this development moves through its cycle, attention should be given to the establishment of positive logistics procedures for the procurement of all expendable materials required for operational use of this equipment.					
	3. The Imagery Analysis Division continues to have a pressing need for this item and is appreciative of the rapid handling our development request has received from the Plans & Development Staff. We are most interested in seeing the formal proposal for this piece of equipment, along with price quotes for the prototype, the operational production models, and expendable materials.					
	*Pistribution:					

Original & 1 - Addressee
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